





ATTORNEY'S DOCKET NO: G0631/7010 (SJH)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Seamus Paul Whiston et al

Serial No:

09/480,223

Confirmation No.: 4079

Filed: For:

January 10, 2000

METHÓD FOR FORMING A DMOS DEVICE AND A DMOS

DEVICE

Examiner:

Y.B. Huynh 2813

Art Unit:

CERTIFICATE OF MAILING UNDER 37 C.F.R. §1.8(a)

The undersigned hereby certifies that this document is being placed in the United States mail with first-class postage attached, addressed to Commissioner for Patents, Washington, D.C. 20231, on the 12th day of July, 2002.

> Steven J. Henry Reg. No. 27,900

COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

Transmitted herewith are the following documents:

Amendment [x]

Petition for Three Month Extension of Time [X]

Return Receipt Postcard [x]

TECHNOLOGY CENTER 2800

If the enclosed papers are considered incomplete, the Mail Room and/or the Application Branch is respectfully requested to contact the undersigned at (617)720-3500. Boston. Massachusetts.

A check for \$920.00 is enclosed for the one-month extension of time. If the fee is insufficient, the balance may be charged to Deposit Account No. 23/2825. A duplicate of this sheet is enclosed.

Respectfully Submitted,

Steven J. Henry Reg. No. 27,900

Wolf, Greenfield & Sacks, P.C.

600 Atlantic Avenue

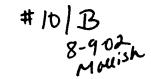
Boston, MA 02210-2211

(617) 720-3500

Docket No. G0631/7010 July 12, 2002

Date: x07/31/02





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METHOD FOR FORMING A DMOS DEVICE AND A DMOS

DEVICE

Examiner:

N. Richards

Art Unit:

2815

CERTIFICATE OF MAILING UNDER 37 C.F.R. §1.8(a)

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Sir:

AMENDMENT

TECHNOLOGY CENTER 2800

In response to the Official Action mailed January 31, 2002, kindly amend the above-identified application as follows:

IN THE CLAIMS:

Please amend claims 1 and 13 as follows (a marked-up copy of the amended claims is attached):

(Amended) A method for forming a body region in a drain region of a DMOS device on a wafer after a gate has been formed with the body region extending partly beneath the gate of the DMOS device and appropriately aligned with the gate, the drain region defining a surface plane, the method comprising the steps of: